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(54) **METHOD OF COMPENSATING AGING IN AN OLED DISPLAY**

VERFAHREN ZUR ALTERUNGSKOMPENSATION EINER OLED-ANZEIGE

METHODE DE COMPENSATION DE VIEILLISSEMENT D'UN ECRAN À DIODES
ÉLECTROLUMINESCENTES ORGANIQUES

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- **JAE-HOON LEE ET AL: "P-12: A New a-Si:H TFT Pixel Design Compensating Threshold Voltage Degradation of TFT and OLED" 2004 SID INTERNATIONAL SYMPOSIUM. SEATTLE, WA, MAY 25 - 27, 2004; [SID INTERNATIONAL SYMPOSIUM], SAN JOSE, CA : SID, US, vol. XXXV, 25 May 2004 (2004-05-25), pages 264-267, XP007012052**

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Description**FIELD OF THE INVENTION**

5 **[0001]** The present invention relates to solid-state OLED flat-panel displays and more particularly to such displays having ways to compensate for the aging of the organic light emitting display components.

BACKGROUND OF THE INVENTION

10 **[0002]** Solid-state organic light-emitting diode (OLED) displays are of great interest as a superior flat-panel display technology. These displays utilize current passing through thin films of organic material to generate light. The color of light emitted and the efficiency of the energy conversion from current to light are determined by the composition of the organic thin-film material. Different organic materials emit different colors of light. However, as the display is used, the organic materials in the display age and become less efficient at emitting light. This reduces the lifetime of the display.
 15 The differing organic materials can age at different rates, causing differential color aging and a display whose white point varies as the display is used. In addition, each individual pixel can age at a rate different from other pixels, resulting in display nonuniformity. Further, some circuitry elements, e.g. amorphous silicon transistors, are also known to exhibit aging effects.

20 **[0003]** The rate at which the materials age is related to the amount of current that passes through the display and, hence, the amount of light that has been emitted from the display. One technique to compensate for this aging effect in polymer light-emitting diodes is described in U.S. Pat. No. 6,456,016 by Sundahi et al. This approach relies on a controlled reduction of current provided at an early stage of use followed by a second stage in which the display output is gradually decreased. This solution requires that a timer within the controller, which then provides a compensating amount of current, track the operating time of the display. Moreover, once a display has been in use, the controller must remain
 25 associated with that display to avoid errors in display operating time. This technique has the disadvantage of not representing the performance of small-molecule organic light emitting diode displays well. Moreover, the time the display has been in use must be accumulated, requiring timing, calculation, and storage circuitry in the controller. Also, this technique does not accommodate differences in behavior of the display at varying levels of brightness and temperature and cannot accommodate differential aging rates of the different organic materials.

30 **[0004]** U.S. Pat. No. 6,414,661 B1 by Shen et al. describes a method and associated system to compensate for long-term variations in the light-emitting efficiency of individual organic light-emitting diodes (OLEDs) in an OLED display by calculating and predicting the decay in light output efficiency of each pixel based on the accumulated drive current applied to the pixel. The method derives a correction coefficient that is applied to the next drive current for each pixel. This technique requires the measurement and accumulation of drive current applied to each pixel, requiring a stored
 35 memory that must be continuously updated as the display is used, and therefore requiring complex and extensive circuitry.

[0005] U.S. Patent Application 2002/0167474 A1 by Everitt describes a pulse width modulation driver for an OLED display. One embodiment of a video display comprises a voltage driver for providing a selected voltage to drive an organic light-emitting diode in a video display. The voltage driver can receive voltage information from a correction table that accounts for aging, column resistance, row resistance, and other diode characteristics. In one embodiment of the
 40 invention, the correction tables are calculated prior to or during normal circuit operation. Since the OLED output light level is assumed to be linear with respect to OLED current, the correction scheme is based on sending a known current through the OLED diode for a duration sufficiently long to allow the transients to settle out, and then measuring the corresponding voltage with an analog-to-digital converter (A/D) residing on the column driver. A calibration current source and the A/D can be switched to any column through a switching matrix.

45 **[0006]** U.S. Pat. No. 6,504,565 B1 by Narita et al. describes a light-emitting display which includes a light-emitting element array formed by arranging a plurality of light-emitting elements, a driving unit for driving the light-emitting element array to emit light from each of the light-emitting elements, a memory unit for storing the number of light emissions for each light-emitting element of the light-emitting element array, and a control unit for controlling the driving unit based on the information stored in the memory unit so that the amount of light emitted from each light-emitting element is held
 50 constant. An exposure display employing the light-emitting display, and an image-forming apparatus employing the exposure display are also disclosed. This design requires the use of a calculation unit responsive to each signal sent to each pixel to record usage, greatly increasing the complexity of the circuit design.

[0007] JP 2002278514 A by Numeo Koji describes a method in which a prescribed voltage is applied to organic EL elements by a current-measuring circuit, the current flows are measured, and a temperature measurement circuit estimates the temperature of the organic EL elements. A comparison is made with the voltage value applied to the elements, the flow of current values and the estimated temperature, the changes due to aging of similarly constituted elements determined beforehand, the changes due to aging in the current-luminance characteristics, and the temperature at the time of the characteristics measurements for estimating the current-luminance characteristics of the elements. Then,

the total sum of the amount of currents being supplied to the elements in the interval during which display data are displayed is changed, which can provide the luminance that is to be originally displayed, based on the estimated values of the current-luminance characteristics, the values of the current flowing in the elements, and the display data. This design presumes a predictable relative use of pixels and does not accommodate differences in actual usage of groups of pixels or of individual pixels. Hence, correction for color or spatial groups is likely to be inaccurate over time. Moreover, the integration of temperature and multiple current sensing circuits within the display is required. This integration is complex, reduces manufacturing yields, and takes up space within the display.

[0008] U.S. Patent Application 2003/0122813 A1 by Ishizuki et al. discloses a display panel driving device and driving method for providing high-quality images without irregular luminance even after long-time use. The light-emission drive current flowing is measured while each pixel successively and independently emits light. Then the luminance is corrected for each input pixel data based on the measured drive current values. According to another aspect, the drive voltage is adjusted such that one drive current value becomes equal to a predetermined reference current. In a further aspect, the current is measured while an off-set current, corresponding to a leak current of the display panel, is added to the current output from the drive voltage generator circuit, and the resultant current is supplied to each of the pixel portions. The measurement techniques are iterative, and therefore slow.

[0009] Arnold et al., in US 6,995,519, teach a method of compensating for aging of an OLED device. This method assumes that the entire change in device luminance is caused by changes in the OLED emitter. However, when the drive transistors in the circuit are formed from amorphous silicon (a-Si), this assumption is not valid, as the threshold voltage of the transistors also changes with use. The method of Arnold will not provide complete compensation for OLED efficiency losses in circuits wherein transistors show aging effects. Additionally, when methods such as reverse bias are used to mitigate a-Si transistor threshold voltage shifts, compensation of OLED efficiency loss can become unreliable without appropriate tracking/prediction of reverse bias effects, or a direct measurement of the OLED voltage change or transistor threshold voltage change.

[0010] WO 2005/109389 A1 describes a circuit for an element of a light-emitting display. Transistors are arranged as first and second switching means of the element to measure a combined electrical parameter of a current control means and a light-emitting means.

[0011] There is a need therefore for a more complete compensation approach for organic light emitting diode displays.

SUMMARY OF THE INVENTION

[0012] It is therefore an object of the present invention to compensate for aging and efficiency changes in OLED emitters in the presence of transistor aging.

[0013] This object is achieved by a method of compensating for changes in characteristics of an OLED drive circuit, comprising:

- a. providing a drive transistor with a first electrode, a second electrode, and a gate electrode;
- b. providing a first voltage source and a first switch for selectively connecting the first voltage source to the first electrode of the drive transistor;
- c. providing an OLED device connected to the second electrode of the drive transistor, and a second voltage source and a second switch for selectively connecting the OLED device to the second voltage source;
- d. connecting the first electrode of a readout transistor to the second electrode of the drive transistor;
- e. providing a current source and a third switch for selectively connecting the current source to the second electrode of the readout transistor;
- f. providing a current sink and a fourth switch for selectively connecting the current sink to the second electrode of the readout transistor;
- g. providing a test voltage to the gate electrode of the drive transistor and providing a voltage measurement circuit connected to the second electrode of the readout transistor;
- h. closing the first and fourth switches, and opening the second and third switches and using the voltage measurement circuit to measure the voltage at the second electrode of the readout transistor to provide a first signal representative of characteristics of the drive transistor;
- i. opening the first and fourth switches, and closing the second and third switches and using the voltage measurement circuit to measure the voltage at the second electrode of the readout transistor to provide a second signal representative of characteristics of the OLED device; and
- j. using the first and second signals to compensate for changes in characteristics of the OLED drive circuit.

ADVANTAGES

[0014] An advantage of this invention is an OLED display that compensates for the aging of the organic materials in

the display wherein circuitry aging is also occurring, without requiring extensive or complex circuitry for accumulating a continuous measurement of light-emitting element use or time of operation. It is a further advantage of this invention that it uses simple voltage measurement circuitry. It is a further advantage of this invention that by making all measurements of voltage, it is more sensitive to changes than methods that measure current. It is a further advantage of this invention that it performs the compensation based on OLED changes, without being confounded with changes in driving transistor properties. It is a further advantage of this invention that compensation for changes in driving transistor properties can be performed with compensation for the OLED changes, thus providing a complete compensation solution. It is a further advantage of this invention that both aspects of measurement and compensation (OLED and driving transistor) can be accomplished rapidly. It is a further advantage of this invention that a single select line can be used to enable data input and data readout. It is a further advantage of this invention that characterization and compensation of driving transistor and OLED changes are unique to the specific element and are not impacted by other elements that may be open-circuited or short-circuited.

BRIEF DESCRIPTION OF THE DRAWINGS

[0015]

FIG. 1 is a schematic diagram of one embodiment of an OLED display that can be used in the practice of the present invention;

FIG. 2 is a schematic diagram of one embodiment of an OLED drive circuit that can be used in the practice of the present invention;

FIG. 3A is a diagram illustrating the effect of aging of an OLED device on luminance efficiency;

FIG. 3B is a diagram illustrating the effect of aging of an OLED device or a drive transistor on device current;

FIG. 4 is a block diagram of one embodiment of the method of the present invention;

FIG. 5 is a graph showing the relationship between OLED efficiency and the change in OLED voltage;

FIG. 6 is a cross-sectional diagram representing the structure of a prior art OLED device useful with the present invention.

DETAILED DESCRIPTION OF THE INVENTION

[0016] Turning now to FIG. 1, there is shown a schematic diagram of one embodiment of an OLED display that can be used in the practice of the present invention. OLED display **10** comprises an array of a predetermined number of OLED devices **50** arranged in rows and columns, wherein each OLED device **50** is a pixel of OLED display **10**. Each OLED device is associated with a corresponding OLED drive circuit whose nature will become apparent. OLED display **10** includes a plurality of row select lines **20** wherein each row of OLED devices **50** has a select line **20**. OLED display **10** includes a plurality of readout lines **30** wherein each column of OLED devices **50** has a readout line **30**. Each readout line **30** is connected to a switch block **130**, which connects readout line **30** to either current source **160** or current sink **165** during the calibration process. Although not shown for clarity of illustration, each column of OLED devices **50** also has a data line as well-known in the art. The plurality of readout lines **30** is connected to one or more multiplexers **40**, which permits parallel/sequential readout of signals from OLED drive circuits, as will become apparent. Multiplexer **40** can be a part of the same structure as OLED display **10**, or can be a separate construction that can be connected to or disconnected from OLED display **10**.

[0017] Turning now to FIG. 2, there is shown a schematic diagram of one embodiment of an OLED drive circuit that can be used in the practice of the present invention. OLED drive circuit **60** includes OLED device **50**, drive transistor **70**, capacitor **75**, readout transistor **80**, and select transistor **90**. Each of the transistors has a first electrode, a second electrode, and a gate electrode. A first voltage source **140** can be selectively connected to the first electrode of drive transistor **70** by first switch **110**, which can be located on the OLED display substrate or on a separate structure. By connected, it is meant that the elements are directly connected or connected via another component, e.g. a switch, a diode, or another transistor. The second electrode of drive transistor **70** is connected to OLED device **50**, and a second voltage source **150** can be selectively connected to OLED device **50** by second switch **120**, which can also be off the OLED display substrate. At least one first switch **110** and second switch **120** are provided for the OLED display. Additional first and second switches can be provided if the OLED display has multiple powered subgroupings of pixels. In normal display mode, the first and second switches are closed, while other switches (described below) are open. The gate electrode of drive transistor **70** is connected to select transistor **90** to selectively provide data from data line **35** to drive transistor **70** as well known in the art. The row select line **20** is connected to the gate electrodes of the select transistors **90** in the row of OLED drive circuits **60**. The gate electrode of select transistor **90** is connected to the gate electrode of readout transistor **80**.

[0018] The first electrode of readout transistor **80** is connected to the second electrode of drive transistor **70** and to

OLED device **50**. The readout line **30** is connected to the second electrodes of the readout transistors **80** in a column of pixel circuits **60**. Readout line **30** is connected to switch block **130**. One switch block **130** is provided for each column of OLED drive circuits **60**. Switch block **130** includes a third switch S3 and a fourth switch S4, and a No-Connect state NC. While the third and fourth switches can be individual entities, they are never closed simultaneously in this method, and thus switch block **130** provides a convenient embodiment of the two switches. The third switch allows current source **160** to be selectively connected to the second electrode of readout transistor **80**. Current source **160**, when connected by the third switch, allows a predetermined constant current to flow into OLED drive circuit **60**. The fourth switch allows current sink **165** to be selectively connected to the second electrode of readout transistor **80**. Current sink **165**, when connected by the fourth switch, allows a predetermined constant current to flow from OLED drive circuit **60** when a predetermined data value is applied to data line **35**. Switch block **130**, current source **160**, and current sink **165** can be provided located on or off the OLED display substrate.

[0019] The second electrode of readout transistor **80** is also connected to voltage measurement circuit **170**, which measures voltages to provide signals representative of characteristics of OLED drive circuit **60**. Voltage measurement circuit **170** comprises at least analog-to-digital converter **185** for converting voltage measurements into digital signals, and processor **190**. The signal from analog-to-digital converter **185** is sent to processor **190**. Voltage measurement circuit **170** can also include memory **195** for storing voltage measurements, and a low-pass filter **180** if necessary. Voltage measurement circuit **170** can be connected through readout line **45** and multiplexer **40** to a plurality of readout lines **30** and readout transistors **80** for sequentially reading out the voltages from a predetermined number of OLED drive circuits **60**. If there are a plurality of multiplexers **40**, each can have its own readout line **45**. Thus, a predetermined number of OLED drive circuits can be driven simultaneously. The plurality of multiplexers will allow parallel reading out of the voltages from the various multiplexers **40**, while each multiplexer would allow sequential reading out of the readout lines **30** attached to it. This will be referred to herein as a parallel/sequential process.

[0020] Processor **190** can also be connected to data line **35** by way of control line **95** and digital-to-analog converter **155**. Thus, processor **190** can provide predetermined data values to data line **35** during the measurement process to be described herein. Processor **190** can also accept display data via data in **85** and provide compensation for changes as will be described herein, thus providing compensated data to data line **35** during the display process.

[0021] Transistors such as drive transistor **70** of OLED drive circuit **60** have a characteristic threshold voltage (V_{th}). The voltage on the gate electrode of drive transistor **70** must be greater than the threshold voltage to enable current flow between the first and second electrodes. When drive transistor **70** is an amorphous silicon transistor, the threshold voltage is known to change under aging conditions. Such conditions include placing drive transistor **70** under actual usage conditions, thereby leading to an increase in the threshold voltage. Therefore, a constant signal on the gate electrode will cause a gradually decreasing light intensity emitted by OLED device **50**. The amount of such decrease will depend upon the use of drive transistor **70**; thus, the decrease can be different for different drive transistors in a display, herein termed spatial variations in characteristics of OLED drive circuits **60**. Such spatial variations can include differences in brightness and color balance in different parts of the display, and image "burn-in" wherein an often-displayed image (e.g. a network logo) can cause a ghost of itself to always show on the active display. It is desirable to compensate for such changes in the threshold voltage to prevent such problems. Also, there can be age-related changes to OLED device **50**, e.g. luminance efficiency loss and an increase in resistance across OLED device **50**.

[0022] Turning now to FIG. 3A, there is shown a diagram illustrating the effect of aging of an OLED device on luminance efficiency as current is passed through the OLED devices. The three curves represent typical performance of different light emitters emitting differently colored light (e.g. R,G,B representing red, green and blue light emitters, respectively) as represented by luminance output over time or cumulative current. The decay in luminance between the differently colored light emitters can be different. The differences can be due to different aging characteristics of materials used in the differently colored light emitters, or due to different usages of the differently colored light emitters. Hence, in conventional use, with no aging correction, the display can become less bright and the color of the display-in particular the white point-can shift.

[0023] Turning now to FIG. 3B, there is shown a diagram illustrating the effect of aging of an OLED device or a drive transistor, or both, on device current. In describing OLED drive circuit change, the horizontal axis of FIG. 3B represents the gate voltage at drive transistor **70**. As the circuit ages, a greater voltage is required to obtain a desired current; that is, the curve moves by an amount ΔV . ΔV is the sum of the change in threshold voltage (ΔV_{th} , **210**) and the change in OLED voltage resulting from a change in OLED device resistance (ΔV_{OLED} , **220**), as shown. This change results in reduced performance. A greater gate voltage is required to obtain a desired current. The relationship between the OLED current (which is also the drain-source current through the drive transistor), OLED voltage, and threshold voltage at saturation is:

$$I_{oled} = \frac{W\mu C_0}{2L} (V_{gs} - V_{th})^2 = \frac{K}{2} (V_g - V_{oled} - V_{th})^2 \quad (\text{Eq. 1})$$

where W is the TFT Channel Width, L is the TFT Channel Length, μ is the TFT mobility, C_0 is the Oxide Capacitance per Unit Area, V_g is the gate voltage, V_{gs} is voltage difference between gate and source of the drive transistor. For simplicity, we neglect dependence of μ on V_{gs} . Thus, to keep the current constant, one must correct for change in V_{th} and V_{OLED} . It is therefore desirable to measure both changes.

[0024] Turning now to FIG. 4, and referring also to FIG. 2, there is shown a block diagram of one embodiment of the method of the present invention. A predetermined test voltage (V_{data}) is provided to data line **35** (Step **310**). First switch **110** is closed and second switch **120** is opened. The fourth switch is closed and the third switch is opened, that is, switch block **130** is switched to S4 (Step **315**). Select line **20** is made active for a selected row to provide the test voltage to the gate electrode of drive transistor **70** and to turn on readout transistor **80** (Step **320**). A current thus flows from first voltage source **140** through drive transistor **70** to current sink **165**. The value of current (I_{testsk}) through current sink **165** is selected to be less than the resulting current through drive transistor **70** due to the application of V_{data} ; a typical value will be in the range of 1 to 5 microamps and will be constant for all measurements during the lifetime of the OLED drive circuit. The selected value of V_{data} is constant for all such measurements during the lifetime of the circuit, and therefore must be sufficient to provide a current through drive-transistor **70** greater than that at current sink **165** even after aging expected during the lifetime of the display. Thus, the limiting value of current through drive transistor **70** will be controlled entirely by current sink **165**, which will be the same as through drive transistor **70**. The value of V_{data} can be selected based upon known or determined current-voltage and aging characteristics of drive transistor **70**. More than one measurement value can be used in this process, e.g. one can choose to do the measurement at 1, 2, and 3 microamps using a value of V_{data} that is sufficient to remain constant for the largest current during the lifetime of the OLED drive circuit. Voltage measurement circuit **170** is used to measure the voltage on readout line **30**, which is the voltage V_{out} at the second electrode of readout transistor **80**, providing a first signal V_1 that is representative of characteristics of drive transistor **70** (Step **325**), including the threshold voltage V_{th} of drive transistor **70**. If the OLED display incorporates a plurality of OLED drive circuits and there are additional OLED drive circuits in the row to be measured, multiplexer **40** connected to a plurality of readout lines **30** can be used to allow voltage measurement circuit **170** to sequentially read out the first signals V_1 from a predetermined number of OLED drive circuits, e.g. every circuit in the row (Step **330**). If the display is sufficiently large, it can require a plurality of multiplexers wherein the first signal can be provided in a parallel/sequential process. If there are additional rows of circuits to be measured (Step **335**), a different row is selected by a different select line and the measurements are repeated. The voltages of the components in the circuit can be related by:

$$V_1 = V_{data} - V_{gs(Itestsk)} - V_{read} \quad (\text{Eq. 2})$$

where $V_{gs(Itestsk)}$ is the gate-to-source voltage that must be applied to drive transistor **70** such that its drain-to-source current, I_{ds} , is equal to I_{testsk} .

[0025] The values of these voltages will cause the voltage at the second electrode of readout transistor **80** (V_{out}) to adjust to fulfill Eq. 2. Under the conditions described above, V_{data} is a set value and V_{read} can be assumed to be constant. V_{gs} will be controlled by the value of the current set by current sink **165** and the current-voltage characteristics of drive transistor **70**, and will change with age-related changes in the threshold voltage of the drive transistor. To determine the change in the threshold voltage of drive transistor **70**, two separate test measurements are performed. The first measurement is performed when drive transistor **70** is not degraded by aging, e.g. before OLED drive circuit **60** is used for display purposes, to cause the voltage V_1 to be at a first level, which is measured and stored. Since this is with zero aging, it can be the ideal first signal value, and will be termed the first target signal. After drive transistor **70** has aged, e.g. by displaying images for a predetermined time, the measurement is repeated and stored. The stored results can be compared. Changes to the threshold voltage of drive transistor **70** will cause a change to V_{gs} to maintain the current. These changes will be reflected in changes to V_1 in Eq. 2, so as to produce voltage V_1 at a second level, which can be measured and stored. Changes in the corresponding stored signals can be compared to calculate a change in the readout voltage V_1 , which is related to the changes in drive transistor **70** as follows:

$$\Delta V_1 = -\Delta V_{gs} = -\Delta V_{th} \quad (\text{Eq. 3})$$

[0026] The above method requires that a first level for V_1 for each drive circuit be stored in memory for later comparison. A less memory-intensive method can be used that does not require an initial measurement, but can compensate for spatial variations in the threshold voltage. After aging, the value of V_1 can be recorded for each drive circuit with selected values for current sink **165**, as previously described. Then, the drive circuit with the minimum V_{th} shift (that is, the maximum measured V_1) is selected as the first target signal, $V_{1target}$, from the population of drive circuits measured. The differences in the threshold voltages of the other drive circuits can be expressed as:

$$\Delta V_1 = -\Delta V_{th} = V_1 - V_{1target} \quad (\text{Eq. 4})$$

[0027] First switch **110** is then opened and second switch **120** is closed. Switch block **130** is switched to S3, thereby opening the fourth switch and closing the third switch (Step **340**). Select line **20** is made active for a selected row to turn on readout transistor **70** (Step **345**). A current, I_{testsu} , thus flows from current source **160** through OLED device **50** to second voltage source **150**. The value of current through current source **160** is selected to be less than the maximum current possible through OLED device **50**; a typical value will be in the range of 1 to 5 microamps and will be constant for all measurements during the lifetime of the OLED drive circuit. More than one measurement value can be used in this process, e.g. one can choose to do the measurement at 1, 2, and 3 microamps. Voltage measurement circuit **170** is used to measure the voltage on readout line **30**, which is the voltage V_{out} at the second electrode of readout transistor **80**, providing a second signal V_2 that is representative of characteristics of OLED device **50**, including the resistance of OLED device **50** (Step **350**). If there are additional OLED drive circuits in the row to be measured, multiplexer **40** connected to a plurality of readout lines **30** can be used to allow voltage measurement circuit **170** to sequentially read out the second signal V_2 for a predetermined number of OLED drive circuits, e.g. every circuit in the row (Step **355**). If the display is sufficiently large, it can require a plurality of multiplexers wherein the second signal can be provided in a parallel/sequential process. If there are additional rows of circuits to be measured in OLED display **10**, Steps **345** to **355** are repeated for each row (Step **360**). The voltages of the components in the circuit can be related by:

$$V_2 = CV + V_{OLED} + V_{read} \quad (\text{Eq. 5})$$

[0028] The values of these voltages will cause the voltage at the second electrode of readout transistor **80** (V_{out}) to adjust to fulfill Eq. 4. Under the conditions described above, CV is a set value and V_{read} can be assumed to be constant. V_{OLED} will be controlled by the value of current set by current source **160** and the current-voltage characteristics of OLED device **50**. V_{OLED} can change with age-related changes in OLED device **50**. To determine the change in V_{OLED} , two separate test measurements are performed. The first measurement is performed when OLED device **50** is not degraded by aging, e.g. before OLED drive circuit **60** is used for display purposes, to cause the voltage V_2 to be at a first level, which is measured and stored. Since this is with zero aging, it can be the ideal second signal value, and will be termed the second target signal. After OLED device **50** has aged, e.g. by displaying images for a predetermined time, the measurement is repeated and stored. The stored results can be compared. Changes in OLED device **50** can cause changes to V_{OLED} to maintain the current. These changes will be reflected in changes to V_2 in Eq. 4, so as to produce voltage V_2 at a second level, which can be measured and stored. Changes in the corresponding stored signals can be compared to calculate a change in the readout voltage, which is related to the changes in OLED device **50** as follows:

$$\Delta V_2 = \Delta V_{OLED} \quad (\text{Eq. 6})$$

[0029] The above method requires that a first level for V_2 for each drive circuit be stored in memory for later comparison. A less memory-intensive method can be used that does not require an initial measurement, but can compensate for spatial variations in V_{OLED} . After aging, the value of V_2 can be recorded for each drive circuit with selected values for current source **160**, as previously described. Then, the drive circuit with the minimum V_{OLED} shift (that is, the minimum measured V_2) is selected as the second target signal, $V_{2target}$, from the population of drive circuits measured. The differences in the threshold voltages of the other drive circuits can be expressed as:

$$\Delta V_2 = \Delta V_{OLED} = V_2 - V_{2target} \quad (\text{Eq. 7})$$

[0030] The changes in the first and second signals can then be used to compensate for changes in characteristics of OLED drive circuit 60 (Step 370). For compensating for the change in current, it is necessary to make a correction for ΔV_{th} (related to ΔV_1) and ΔV_{OLED} (related to ΔV_2). However, a third factor also affects the luminance of the OLED device and change with age or use: the efficiency of the OLED device decreases, which decreases the light emitted at a given current (shown in FIG. 3A). In addition to the relations above, a relationship has been found between the decrease in luminance efficiency of an OLED device and ΔV_{OLED} , that is, where the OLED luminance for a given current is a function of the change in V_{OLED} :

$$\frac{L_{OLED}}{I_{OLED}} = f(\Delta V_{OLED}) \quad (\text{Eq. 8})$$

[0031] An example of the relationship between luminance efficiency and ΔV_{OLED} for one device is shown in the graph in FIG. 5. By measuring the luminance decrease and its relationship to ΔV_{OLED} with a given current, a change in corrected signal necessary to cause the OLED device 50 to output a nominal luminance can be determined. This measurement can be done on a model system and thereafter stored in a lookup table or used as an algorithm.

[0032] To compensate for the above changes in characteristics of OLED drive circuit 60, one can use the changes in the first and second signals in an equation of the form:

$$\Delta V_{data} = f_1(\Delta V_1) + f_2(\Delta V_2) + f_3(\Delta V_2) \quad (\text{Eq. 9})$$

where ΔV_{data} is an offset voltage on the gate electrode of drive transistor 70 necessary to maintain the desired luminance, $f_1(\Delta V_1)$ is a correction for the change in threshold voltage, $f_2(\Delta V_2)$ is a correction for the change in OLED resistance, and $f_3(\Delta V_2)$ is a correction for the change in OLED efficiency. For example, the OLED display can include a controller, which can include a lookup table or algorithm to compute an offset voltage for each OLED device. The offset voltage is computed to provide corrections for changes in current due to changes in the threshold voltage of drive transistor 70 and aging of OLED device 50, as well as providing a current increase to compensate for efficiency loss due to aging of OLED device 50, thus providing a complete compensation solution. These changes can be applied by the controller to correct the light output to the nominal luminance value desired. By controlling the signal applied to the OLED device, an OLED device with a constant luminance output and increased lifetime at a given luminance is achieved. Because this method provides a correction for each OLED device in a display, it will compensate for spatial variations in the characteristics of the plurality of OLED drive circuits.

[0033] In a preferred embodiment, the invention is employed in a display that includes Organic Light Emitting Diodes (OLEDs), which are composed, of small molecule or polymeric OLEDs as disclosed in but not limited to U.S. Pat. No. 4,769,292, by Tang et al., and U.S. Pat. No. 5,061,569, by VanSlyke et al. Many combinations and variations of organic light emitting displays can be used to fabricate such a display.

[0034] There are numerous configurations of the organic layers in an OLED device wherein the present invention can be successfully practiced. A typical prior art structure is OLED device 50 shown in FIG. 6 and is comprised of a substrate 401, an anode 403, a hole-injecting layer 405, a hole-transporting layer 407, a light-emitting layer 409, an electron-transporting layer 411, and a cathode 413. These layers are described in detail below. Note that the substrate can alternatively be located adjacent to the cathode, or the substrate can actually constitute the anode or cathode. The organic layers between the anode and cathode are conveniently referred to as the organic EL element. The total combined thickness of the organic layers is preferably less than 500 nm. The device can be top-emitting (light is emitted through cathode 413) or bottom-emitting (light is emitted through anode 403 and substrate 401).

[0035] The anode and cathode of the OLED are connected to a voltage/current source 450 through electrical conductors 460. The OLED is operated by applying a potential between the anode and cathode such that the anode is at a more positive potential than the cathode. Holes are injected into the organic EL element from the anode and electrons are injected into the organic EL element at the cathode. Enhanced display stability can sometimes be achieved when the OLED is operated in an AC mode where, for some time period in the cycle, the potential bias is reversed and no current flows. An example of an AC-driven OLED is described in U.S. Pat. No. 5,552,678.

[0036] The OLED display of this invention is typically provided over a supporting substrate where either the cathode or anode can be in contact with the substrate. The electrode in contact with the substrate is conveniently referred to as the bottom electrode. Conventionally, the bottom electrode is the anode, but this invention is not limited to that configuration. The substrate can either be transmissive or opaque. In the case wherein the substrate is transmissive but the device is top-emitting, a reflective or light absorbing layer can be used to reflect the light or to absorb the light, thereby

improving the contrast of the display. Substrates can include, but are not limited to, glass, plastic, semiconductor materials, silicon, ceramics, and circuit board materials. This invention is particularly useful when the substrate includes an amorphous silicon portion that is used to form the drive circuitry.

[0037] When EL emission is viewed through anode **403**, the anode should be transparent or substantially transparent to the emission of interest. Common transparent anode materials used in this invention are indium-tin oxide (ITO), indium-zinc oxide (IZO) and tin oxide, but other metal oxides can work including, but not limited to, aluminum-or indium-doped zinc oxide, magnesium-indium oxide, and nickel-tungsten oxide. In addition to these oxides, metal nitrides, such as gallium nitride, and metal selenides, such as zinc selenide, and metal sulfides, such as zinc sulfide, can be used as the anode. For applications where EL emission is viewed only through the cathode electrode, the transmissive characteristics of anode are immaterial and any conductive material can be used, transparent, opaque or reflective. Example conductors for this application include, but are not limited to, gold, iridium, molybdenum, palladium, and platinum. Typical anode materials, transmissive or otherwise, have a work function of 4.1 eV or greater. Desired anode materials are commonly deposited by any suitable way such as evaporation, sputtering, chemical vapor deposition, or electrochemical techniques. Anodes can be patterned using well-known photolithographic processes. Optionally, anodes can be polished prior to application of other layers to reduce surface roughness so as to reduce shorts or enhance reflectivity.

[0038] While not always necessary, it is often useful to provide a hole-injecting layer **405** between anode **403** and hole-transporting layer **407**. The hole-injecting material can serve to improve the film formation property of subsequent **organic** layers and to facilitate injection of holes into the hole-transporting layer. Suitable materials for use in the hole-injecting layer include, but are not limited to, porphyrinic compounds as described in U.S. Pat. No. 4,720,432, plasma-deposited fluorocarbon polymers as described in U.S. Pat. No. 6,208,075, and some aromatic amines, for example, m-MTDATA (4,4',4''-tris[(3-methylphenyl)phenylamino]triphenylamine). Alternative hole-injecting materials reportedly useful in organic EL displays are described in EP 0 891 121 A1 and EP 1 029 909 A1.

[0039] The hole-transporting layer **407** contains at least one hole-transporting compound such as an aromatic tertiary amine, where the latter is understood to be a compound containing at least one trivalent nitrogen atom that is bonded only to carbon atoms, at least one of which is a member of an aromatic ring. In one form the aromatic tertiary amine can be an arylamine, such as a monoarylamine, diarylamine, triarylamine, or a polymeric arylamine. In US Pat. No. 3,180,730 Klupfel et al. illustrates exemplary monomeric triarylamine. Other suitable triarylamine substituted with one or more vinyl radicals or comprising at least one active hydrogen containing group are disclosed by Brantley et al U.S. Pat. Nos. 3,567,450 and 3,658,520.

[0040] A more preferred class of aromatic tertiary amines are those which include at least two aromatic tertiary amine moieties as described in U.S. Pat. Nos. 4,720,432 and 5,061,569. The hole-transporting layer can be formed of a single or a mixture of aromatic tertiary amine compounds. Illustrative of useful aromatic tertiary amines are the following:

1,1-Bis(4-di-p-tolylaminophenyl)cyclohexane
 1,1-Bis(4-di-p-tolylaminophenyl)-4-phenylcyclohexane
 4,4'-Bis(diphenylamino)quadriphenyl
 Bis(4-dimethylamino-2-methylphenyl)-phenylmethane
 N,N,N-Tri(p-tolyl)amine
 4-(di-p-tolylamino)-4'-[4(di-p-tolylamino)-styryl] stilbene
 N,N,N',N'-Tetra-p-tolyl-4,4'-diaminobiphenyl
 N,N,N',N'-Tetraphenyl-4,4'-diaminobiphenyl
 N,N,N',N'-tetra-1-naphthyl-4,4'-diaminobiphenyl
 N,N,N',N'-tetra-2-naphthyl-4,4'-diaminobiphenyl
 N-Phenylcarbazole
 4,4'-Bis[N-(1-naphthyl)-N-phenylamino]biphenyl
 4,4'-Bis[N-(1-naphthyl)-N-(2-naphthyl)amino]biphenyl
 4,4''-Bis[N-(1-naphthyl)-N-phenylamino]p-terphenyl
 4,4'-Bis[N-(2-naphthyl)-N-phenylamino]biphenyl
 4,4'-Bis[N-(3-acenaphthenyl)-N-phenylamino]biphenyl
 1,5-Bis[N-(1-naphthyl)-N-phenylamino]naphthalene
 4,4'-Bis[N-(9-anthryl)-N-phenylamino]biphenyl
 4,4''-Bis[N-(1-anthryl)-N-phenylamino]-p-terphenyl
 4,4'-Bis[N-(2-phenanthryl)-N-phenylamino]biphenyl
 4,4'-Bis[N-(8-fluoranthryl)-N-phenylamino]biphenyl
 4,4'-Bis[N-(2-pyrenyl)-N-phenylamino]biphenyl
 4,4'-Bis[N-(2-naphthacenyl)-N-phenylamino]biphenyl
 4,4'-Bis[N-(2-perylene)-N-phenylamino]biphenyl
 4,4'-Bis[N-(1-coroneryl)-N-phenylamino]biphenyl

2,6-Bis(di-p-tolylamino)naphthalene
 2,6-Bis[di-(1-naphthyl)amino]naphthalene
 2,6-Bis[N-(1-naphthyl)-N-(2-naphthyl)amino]naphthalene
 N,N,N',N'-Tetra(2-naphthyl)-4,4"-diamino-p-terphenyl
 4,4'-Bis {N-phenyl-N-[4-(1-naphthyl)-phenyl]amino} biphenyl
 4,4'-Bis[N-phenyl-N-(2-pyrenyl)amino]biphenyl
 2,6-Bis[N,N-di(2-naphthyl)amine]fluorene
 1,5-Bis[N-(1-naphthyl)-N-phenylamino]naphthalene
 4,4',4"-tris[(3-methylphenyl)phenylamino] triphenylamine

[0041] Another class of useful hole-transporting materials includes polycyclic aromatic compounds as described in EP 1 009 041. Tertiary aromatic amines with more than two amine groups can be used including oligomeric materials. In addition, polymeric hole-transporting materials can be used such as poly(N-vinylcarbazole) (PVK), polythiophenes, polypyrrole, polyaniline, and copolymers such as poly(3,4-ethylenedioxythiophene)/poly(4-styrenesulfonate) also called PEDOT/PSS.

[0042] As more fully described in U.S. Pat. Nos. 4,769,292 and 5,935,721, the light-emitting layer (LEL) 409 of the organic EL element includes a luminescent or fluorescent material where electroluminescence is produced as a result of electron-hole pair recombination in this region. The light-emitting layer can be comprised of a single material, but more commonly consists of a host material doped with a guest compound or compounds where light emission comes primarily from the dopant and can be of any color. The host materials in the light-emitting layer can be an electron-transporting material, as defined below, a hole-transporting material, as defined above, or another material or combination of materials that support hole-electron recombination. The dopant is usually chosen from highly fluorescent dyes, but phosphorescent compounds, e.g., transition metal complexes as described in WO 98/55561, WO 00/18851, WO 00/57676, and WO 00/70655 are also useful. Dopants are typically coated as 0.01 to 10% by weight into the host material. Polymeric materials such as polyfluorenes and polyvinylarylenes (e.g., poly (p-phenylenevinylene), PPV) can also be used as the host material. In this case, small molecule dopants can be molecularly dispersed into the polymeric host, or the dopant can be added by copolymerizing a minor constituent into the host polymer.

[0043] An important relationship for choosing a dye as a dopant is a comparison of the bandgap potential which is defined as the energy difference between the highest occupied molecular orbital and the lowest unoccupied molecular orbital of the molecule. For efficient energy transfer from the host to the dopant molecule, a necessary condition is that the band gap of the dopant is smaller than that of the host material. For phosphorescent emitters it is also important that the triplet energy level of the host be high enough to enable energy transfer from host to dopant.

[0044] Host and emitting molecules known to be of use include, but are not limited to, those disclosed in U.S. Pat. Nos. 4,768,292; 5,141,671; 5,150,006; 5,151,629; 5,405,709; 5,484,922; 5,593,788; 5,645,948; 5,683,823; 5,755,999; 5,928,802; 5,935,720; 5,935,721; and 6,020,078.

[0045] Metal complexes of 8-hydroxyquinoline (oxine) and similar derivatives constitute one class of useful host compounds capable of supporting electroluminescence. Illustrative of useful chelated oxinoid compounds are the following:

CO-1: Aluminum trisoxine [alias, tris(8-quinolinolato) aluminum(III)]
 CO-2: Magnesium bisoxine [alias, bis(8-quinolinolato) magnesium(II)]
 CO-3: Bis[benzo(f)-8-quinolinolato]zinc (II)
 CO-4: Bis(2-methyl-8-quinolinolato)aluminum(III)-μ-oxo-bis(2-methyl-8-quinolinolato)aluminum(III)
 CO-5: Indium trisoxine [alias, tris(8-quinolinolato)indium]
 CO-6: Aluminum tris(5-methyloxine)[alias, tris(5-methyl-8-quinolinolato) aluminum(III)]
 CO-7: Lithium oxine [alias, (8-quinolinolato)lithium(I)]
 CO-8: Gallium oxine [alias, tris(8-quinolinolato) gallium(III)]
 CO-9: Zirconium oxine [alias, tetra(8-quinolinolato) zirconium(IV)]

[0046] Other classes of useful host materials include, but are not limited to: derivatives of anthracene, such as 9,10-di-(2-naphthyl) anthracene and derivatives thereof as described in U.S. Pat. No. 5,935,721, distyrylarylene derivatives as described in U.S. Pat. No. 5,121,029, and benzazole derivatives, for example, 2, 2', 2''-(1,3,5-phenylene)tris[1-phenyl-1H-benzimidazole]. Carbazole derivatives are particularly useful hosts for phosphorescent emitters.

[0047] Useful fluorescent dopants include, but are not limited to, derivatives of anthracene, tetracene, xanthene, perylene, rubrene, coumarin, rhodamine, quinacridone, dicyanomethylenepyran compounds, thiopyran compounds, polymethine compounds, pyrilium and thiapyrilium compounds, fluorene derivatives, perflanthene derivatives, indenoperylene derivatives, bis(azinyl)amine boron compounds, bis(azinyl) methane compounds, and carbostyryl compounds.

[0048] Preferred thin film-forming materials for use in forming the electron-transporting layer 411 of the organic EL elements of this invention are metal chelated oxinoid compounds, including chelates of oxine itself (also commonly

referred to as 8-quinolinol or 8-hydroxyquinoline). Such compounds help to inject and transport electrons, exhibit high levels of performance, and are readily fabricated in the form of thin films. Exemplary oxinoid compounds were listed above.

[0049] Other electron-transporting materials include various butadiene derivatives are disclosed in U.S. Pat. No. 4,356,429. Various heterocyclic optical brighteners are described in U.S. Pat. No. 4,539,507. Benzazoles and triazines are also useful electron-transporting materials.

[0050] When light emission is viewed solely through the anode, the cathode **413** used in this invention can be comprised of nearly any conductive material. Desirable materials have good film-forming properties to ensure good contact with the underlying organic layer, promote electron injection at low voltage, and have good stability. Useful cathode materials often contain a low work function metal (<4.0 eV) or metal alloy. One preferred cathode material is comprised of a Mg: Ag alloy wherein the percentage of silver is in the range of 1 to 20%, as described in U.S. Pat. No. 4,885,221. Another suitable class of cathode materials includes bilayers comprising a thin electron-injection layer (EIL) in contact with the organic layer (e.g., ETL), which is capped with a thicker layer of a conductive metal. Here, the EIL preferably includes a low work function metal or metal salt, and if so, the thicker capping layer does not need to have a low work function. One such cathode is comprised of a thin layer of LiF followed by a thicker layer of Al as described in U.S. Pat. No. 5,677,572. Other useful cathode material sets include, but are not limited to, those disclosed in U.S. Pat. Nos. 5,059,861; 5,059,862; and 6,140,763.

[0051] When light emission is viewed through the cathode, the cathode must be transparent or nearly transparent. For such applications, metals must be thin or one must use transparent conductive oxides, or a combination of these materials. Optically transparent cathodes have been described in more detail in U.S. Pat. No. 4,885,211, U.S. Pat. No. 5,247, 190; JP 3,234,963; U.S. Pat. No. 5,703,436; U.S. Pat. No. 5,608,287; U.S. Pat. No. 5,837,391; U.S. Pat. No. 5,677,572; U.S. Pat. No. 5,776,622; U.S. Pat. No. 5,776,623; U.S. Pat. No. 5,714,838; U.S. Pat. No. 5,969,474; U.S. Pat. No. 5,739,545; U.S. Pat. No. 5,981,306, U.S. Pat. No. 6,137,223, U.S. Pat. No. 6,140,763, U.S. Pat. No. 6,172,459; EP 1 076 368; U.S. Pat. No. 6,278,236; and U.S. Pat. No. 6,284,393. Evaporation, sputtering, or chemical vapor deposition typically deposits cathode materials. When needed, patterning can be achieved through many well known methods including, but not limited to, through-mask deposition and integral shadow masking. U.S. Pat. No. 5,276,380 and EP 0 732 868, disclose laser ablation, and selective chemical vapor deposition.

[0052] In some instances, layers **409** and **411** can optionally be collapsed into a single layer that serves the function of supporting both light emission and electron transportation. It also known in the art that light-emitting dopants can be added to the hole-transporting layer, which can serve as a host. Multiple dopants can be added to one or more layers in order to create a white-emitting OLED, for example, by combining blue- and yellow-emitting materials, cyan- and red-emitting materials, or red-, green-, and blue-emitting materials. White-emitting displays are described, for example, in EP 1 187 235, U.S. Pat. No. 5,002,549, EP 1 182 244, U.S. Pat. No. 5,683,823, U.S. Pat. No. 5,503,910, U.S. Pat. No. 5,405,709, and U.S. Pat. No. 5,283,182.

[0053] Additional layers such as electron- or hole-blocking layers as taught in the art can be employed in displays of this invention. Hole-blocking layers are commonly used to improve efficiency of phosphorescent emitter displays, for example, as in U.S. Pat. No. 5,002,549.

[0054] This invention can be used in so-called stacked display architecture, for example, as taught in U.S. Pat. No. 5,703,436 and U.S. Pat. No. 6,337,492.

[0055] The organic materials mentioned above are suitably deposited through a vapor-phase method such as sublimation, but can be deposited from a fluid, for example, from a solvent with an optional binder to improve film formation. If the material is a polymer, solvent deposition is useful but other methods can be used, such as sputtering or thermal transfer from a donor sheet. The material to be deposited by sublimation can be vaporized from a sublimator "boat" often comprised of a tantalum material, e.g., as described in U.S. Pat. No. 6,237,529, or can be first coated onto a donor sheet and then sublimed in closer proximity to the substrate. Layers with a mixture of materials can utilize separate sublimator boats or the materials can be pre-mixed and coated from a single boat or donor sheet. Patterned deposition can be achieved using shadow masks; integral shadow masks (U.S. Pat. No. 5,294,870), spatially-defined thermal dye transfer from a donor sheet (U.S. Pat. Nos. 5,688,551, 5,851,709 and 6,066,357) and inkjet methods (U.S. Pat. No. 6,066,357).

[0056] Most OLED displays are sensitive to moisture or oxygen, or both, so they are commonly sealed in an inert atmosphere such as nitrogen or argon, along with a desiccant such as alumina, bauxite, calcium sulfate, clays, silica gel, zeolites, alkaline metal oxides, alkaline earth metal oxides, sulfates, or metal halides and perchlorates. Methods for encapsulation and desiccation include, but are not limited to, those described in U.S. Pat. No. 6,226,890. In addition, barrier layers such as SiO_x, Teflon, and alternating inorganic/polymeric layers are known in the art for encapsulation.

[0057] OLED displays of this invention can employ various well-known optical effects in order to enhance its properties if desired. This includes selecting layer thicknesses to yield improved light transmission, providing dielectric mirror structures, replacing reflective electrodes with light-absorbing electrodes, providing anti-glare or anti-reflection coatings over the display, providing a polarizing medium over the display, or providing colored, neutral density, or color conversion filters over the display. Filters, polarizers, and anti-glare or anti-reflection coatings can be specifically provided over the cover or an electrode protection layer beneath the cover.

[0058] The invention has been described in detail with particular reference to certain preferred embodiments thereof, but it will be understood that variations and modifications can be effected within the scope of the invention as claimed.

PARTS LIST

5

[0059]

10

10 OLED display

20 select line

30 readout line

35 data line

15

40 multiplexer

45 readout line

20

50 pixel, or OLED device

60 OLED drive circuit

70 drive transistor

25

75 capacitor

80 readout transistor

30

85 data in

90 select transistor

95 control line

35

110 first switch

120 second switch

40

130 switch block

140 first voltage source

150 second voltage source

45

155 digital-to-analog converter

160 current source

50

165 current sink

170 voltage measurement circuit

180 low-pass filter

55

185 analog-to-digital converter

190 processor

195 memory

210 ΔV_{th}

5 220 ΔV_{OLED}

310 step

315 step

10 320 step

325 step

15 330 decision step

335 decision step

340 step

20 345 step

350 step

25 355 decision step

360 decision step

370 step

30 401 substrate

403 anode

35 405 hole injecting layer

407 hole transporting layer

409 light emitting layer

40 411 electron-transporting layer

413 cathode

45 450 voltage/current source

460 electrical conductors

50 **Claims**

1. A method of compensating for changes in characteristics of an OLED drive circuit (60), comprising:
 - a. providing a drive transistor (70) with a first electrode, a second electrode, and a gate electrode;
 - 55 b. providing a first voltage source (140) and a first switch (110) for selectively connecting the first voltage source (140) to the first electrode of the drive transistor (70);
 - c. providing an OLED device (50) connected to the second electrode of the drive transistor (70), and a second voltage source (150) and a second switch (120) for selectively connecting the OLED device (50) to the second

voltage source (150);

d. connecting a first electrode of a readout transistor (80) to the second electrode of the drive transistor (70);

e. providing a current source (160) and a third switch for selectively connecting the current source (160) to a second electrode of the readout transistor (80),

f. providing a current sink (165) and a fourth switch for selectively connecting the current sink (165) to the second electrode of the readout transistor (80);

g. providing a test voltage to the gate electrode of the drive transistor (70) and providing a voltage measurement circuit (170) connected to the second electrode of the readout transistor (80);

h. closing the first and fourth switches, and opening the second and third switches and using the voltage measurement circuit (170) to measure the voltage at the second electrode of the readout transistor (80) to provide a first signal representative of characteristics of the drive transistor (70);

i. opening the first and fourth switches, and closing the second and third switches and using the voltage measurement circuit (170) to measure the voltage at the second electrode of the readout transistor (80) to provide a second signal representative of characteristics of the OLED device (50); and

j. using the first and second signals to compensate for changes in characteristics of the OLED drive circuit (60).

2. The method of claim 1, wherein step j includes storing the first and second signals during separate test measurements, and comparing changes in corresponding stored signals to compensate for changes in characteristics of the OLED drive circuit (60).

3. The method of claim 1, wherein the voltage measurement circuit (170) includes an analog-to-digital converter.

4. The method of claim 3, wherein the voltage measurement circuit (170) further includes a low-pass filter (180).

5. The method of claim 1, further including providing a plurality of OLED drive circuits (60) incorporated in a display, and wherein steps h and i are performed for a predetermined number of such OLED drive circuits (60) during which the predetermined number of drive circuits are driven simultaneously.

6. The method of claim 5, wherein step j includes comparing the measured first and second signals for each of the plurality of OLED drive circuits (60) to first and second target signals, to compensate for spatial variations in characteristics of the OLED drive circuits (60).

7. The method of claim 5, wherein the OLED device (50) circuits are arranged in rows and columns, and further including a plurality of row select lines (20) connected to the gate electrodes of respective select transistors and a plurality of readout lines (30, 45) connected to the second electrodes of respective readout transistors (80).

8. The method of claim 7, further including using a multiplexer (40) connected to the plurality of readout lines (30, 45) for sequentially reading out the first and second signals for the predetermined number of OLED drive circuits (60).

9. The method of claim 1, further including a select transistor (90) connected to the gate electrode of the drive transistor (70), and wherein the gate electrode of the select transistor (90) is connected to the gate electrode of the readout transistor (80).

Patentansprüche

1. Verfahren zur Kompensation von Veränderungen in einer Charakteristik einer OLED-Treiberschaltung (60), umfassend:

a. Bereitstellen eines Treibertransistors (70) mit einer ersten Elektrode, einer zweiten Elektrode und einer Gatterelektrode;

b. Bereitstellen einer ersten Spannungsquelle (140) und eines ersten Schalters (110) zum wahlweisen Verbinden der ersten Spannungsquelle (140) mit der ersten Elektrode des Treibertransistors (70);

c. Bereitstellen einer OLED-Vorrichtung (50), die mit der zweiten Elektrode des Treibertransistors (70) verbunden ist, und einer zweiten Spannungsversorgung (150) und einem zweiten Schalter (120) zum wahlweisen Verbinden der OLED-Vorrichtung (50) mit der zweiten Spannungsversorgung (150);

d. Verbinden einer ersten Elektrode eines Auslesetransistors (80) mit der zweiten Elektrode des Treibertransistors (70);

- e. Bereitstellen einer Stromquelle (160) und eines dritten Schalters zum wahlweisen Verbinden der Stromquelle (160) mit einer zweiten Elektrode des Auslesetransistors (80);
- f. Bereitstellen einer Stromsenke (165) und eines vierten Schalters zum wahlweisen Verbinden der Stromsenke (165) mit der zweiten Elektrode des Auslesetransistors (80);
- g. Bereitstellen einer Testspannung an der Gatterelektrode des Treibertransistors (70) und Bereitstellen einer Spannungsmessschaltung (170), die mit der zweiten Elektrode des Auslesetransistors (80) verbunden ist;
- h. Schließen des ersten und vierten Schalters, und Öffnen des zweiten und dritten Schalters und Verwenden der Spannungsmessschaltung (170) zum Messen der Spannung an der zweiten Elektrode des Auslesetransistors (80) zum Bereitstellen eines ersten Signals, das eine Charakteristik des Treibertransistors (70) darstellt;
- i. Öffnen des ersten und vierten Schalters, und Schließen des zweiten und dritten Schalters und Verwenden der Spannungsmessschaltung (170) zum Messen der Spannung an der zweiten Elektrode des Auslesetransistors (80) zum Bereitstellen eines zweiten Signals, das eine Charakteristik der OLED-Vorrichtung (50) darstellt;
- j. Verwenden des ersten und zweiten Signals zum Kompensieren der Veränderungen in der Charakteristik der OLED-Treiberschaltung (60).

2. Verfahren nach Anspruch 1, wobei der Schritt j umfasst ein Speichern des ersten und zweiten Signals während getrennter Testmessungen und ein Vergleichen von Veränderungen in entsprechenden gespeicherten Signalen zum Kompensieren der Veränderungen in der Charakteristik der OLED-Treiberschaltung (60).
3. Verfahren nach Anspruch 1, wobei die Spannungsmessschaltung (170) einen Analog-zu-digital-Wandler umfasst.
4. Verfahren nach Anspruch 3, wobei die Spannungsmessschaltung (170) ferner einen Tiefpassfilter (180) umfasst.
5. Verfahren nach Anspruch 1, ferner umfassend ein Bereitstellen einer Vielzahl von OLED-Treiberschaltungen (60), die in ein Display eingebracht sind, und wobei die Schritte h und i für eine vorbestimmte Anzahl solcher OLED-Treiberschaltungen (60) ausgeführt werden, währenddessen die vorbestimmte Anzahl an Treiberschaltungen simultan betrieben wird.
6. Verfahren nach Anspruch 5, wobei der Schritt j ein Vergleichen der gemessenen ersten und zweiten Signale umfasst für jede der Vielzahl an OLED-Treiberschaltungen (60) mit ersten und zweiten Sollsignalen zum Kompensieren von räumlichen Abweichungen in der Charakteristik der OLED-Treiberschaltungen (60).
7. Verfahren nach Anspruch 5, wobei die Schaltungen der OLED-Vorrichtung (50) in Reihen und Spalten angeordnet sind, und ferner umfassend eine Vielzahl von Reihenauswahlleitungen (20), die mit den Gatterelektroden jeweiliger Auswahltransistoren verbunden sind, und eine Vielzahl von Ausleseleitungen (30, 45), die mit den zweiten Elektroden des jeweiligen Auslesetransistors (80) verbunden sind.
8. Verfahren nach Anspruch 7, ferner umfassend ein Verwenden eines Multiplexers (40), der mit der Vielzahl von Ausleseleitungen (30, 45) zum sequentiellen Auslesen der ersten und zweiten Signale verbunden ist für die vorbestimmte Anzahl an OLED-Treiberschaltungen (60).
9. Verfahren nach Anspruch 1, ferner einen Auswahltransistor (90) umfassend, der mit der Gatterelektrode des Treibertransistors (70) verbunden ist, und wobei die Gatterelektrode des Auswahltransistors (90) mit der Gatterelektrode des Auslesetransistors (80) verbunden ist.

Revendications

1. Procédé consistant à compenser les changements des caractéristiques d'un circuit d'attaque à diodes électroluminescentes organiques (OLED) (60), comprenant les étapes consistant à :
 - a. prévoir un transistor d'attaque (70) avec une première électrode, une deuxième électrode, et une électrode de grille ;
 - b. prévoir une première source de tension (140) et un premier interrupteur (110) destiné à connecter sélectivement la première source de tension (140) à la première électrode du transistor d'attaque (70) ;
 - c. prévoir un dispositif à diodes électroluminescentes organiques (50) connecté à la deuxième électrode du transistor d'attaque (70), et une deuxième source de tension (150) et un deuxième interrupteur (120) pour connecter sélectivement le dispositif à diodes électroluminescentes organiques (50) à la deuxième source de

tension (150) ;

d. connecter une première électrode d'un transistor de lecture (80) à la deuxième électrode du transistor d'attaque (70) ;

e. prévoir une source de courant (160) et un troisième interrupteur pour connecter sélectivement la source de courant (160) à une deuxième électrode du transistor de lecture (80) ;

f. prévoir un récepteur de courant (165) et un quatrième interrupteur pour connecter sélectivement le récepteur de courant (165) à la deuxième électrode du transistor de lecture (80) ;

g. prévoir une tension de test sur l'électrode de grille du transistor d'attaque (70) et prévoir un circuit de mesure de tension (170) connecté à la deuxième électrode du transistor de lecture (80) ;

h. fermer les premier et quatrième interrupteurs, et ouvrir les deuxième et troisième interrupteurs et utiliser le circuit de mesure de tension (170) pour mesurer la tension au niveau de la deuxième électrode du transistor de lecture (80) pour délivrer un premier signal représentatif des caractéristiques du transistor d'attaque (70) ;

i. ouvrir les premier et quatrième interrupteurs, et fermer les deuxième et troisième interrupteurs et utiliser le circuit de mesure de tension (170) pour mesurer la tension au niveau de la deuxième électrode du transistor de lecture (80) pour délivrer un deuxième signal représentatif des caractéristiques du dispositif à diodes électroluminescentes organiques (50) ; et

j. utiliser les premier et deuxième signaux pour compenser les changements des caractéristiques du circuit d'attaque à diodes électroluminescentes organiques (60).

2. Procédé selon la revendication 1, dans lequel l'étape j comprend l'étape consistant à mémoriser les premier et deuxième signaux pendant des mesures de tests séparées, et comparer les changements dans les signaux mémorisés correspondants pour compenser les changements des caractéristiques du circuit d'attaque à diodes électroluminescentes organiques (60).

3. Procédé selon la revendication 1, dans lequel le circuit de mesure de tension (170) comprend un convertisseur analogique/numérique.

4. Procédé selon la revendication 3, dans lequel le circuit de mesure de tension (170) comprend en outre un filtre passe-bas (180).

5. Procédé selon la revendication 1, comprenant en outre l'étape consistant à prévoir une pluralité de circuits d'attaque à diodes électroluminescentes organiques (60) incorporés dans un affichage, et dans lequel les étapes h et i sont exécutées pour un nombre prédéterminé de tels circuits d'attaque à diodes électroluminescentes organiques (60) pendant lesquelles les circuits d'attaque en nombre prédéterminé sont attaqués simultanément.

6. Procédé selon la revendication 5, dans lequel l'étape j comprend la comparaison des premier et deuxième signaux mesurés pour chacun parmi la pluralité de circuits d'attaque à diodes électroluminescentes organiques (60) aux premier et deuxième signaux cibles, pour compenser les variations spatiales dans les caractéristiques des circuits d'attaque à diodes électroluminescentes organiques (60).

7. Procédé selon la revendication 5, dans lequel dans le dispositif à diodes électroluminescentes organiques (50) des circuits sont disposés en rangées et en colonnes, et comprenant en outre une pluralité de lignes de sélection de rangées (20) connectées aux électrodes de grille des transistors de sélection respectifs et une pluralité de lignes de lecture (30, 45) connectées aux deuxième électrodes des transistors de lecture respectifs (80).

8. Procédé selon la revendication 7, comprenant en outre l'utilisation d'un multiplexeur (40) connecté à la pluralité de lignes de lecture (30, 45) pour lire séquentiellement les premier et deuxième signaux pour le nombre prédéterminé de circuits d'attaque à diodes électroluminescentes organiques (60).

9. Procédé selon la revendication 1, comprenant en outre un transistor de sélection (90) connecté à l'électrode de grille du transistor d'attaque (70), et dans lequel l'électrode de grille du transistor de sélection (90) est connectée à l'électrode de grille du transistor de lecture (80).

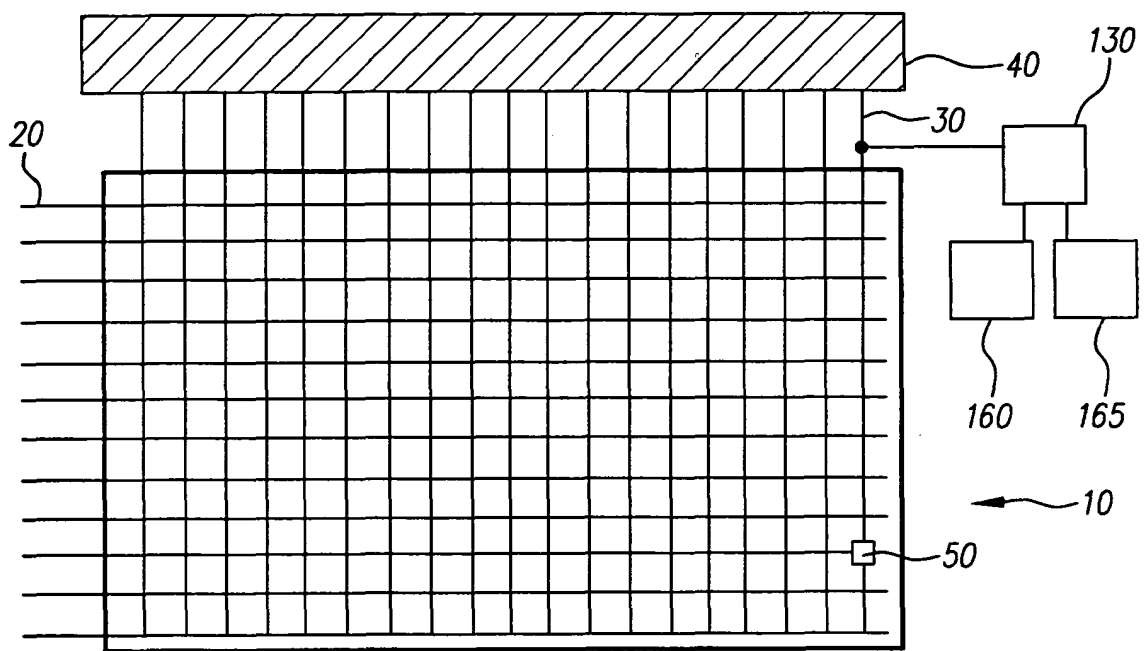


FIG. 1

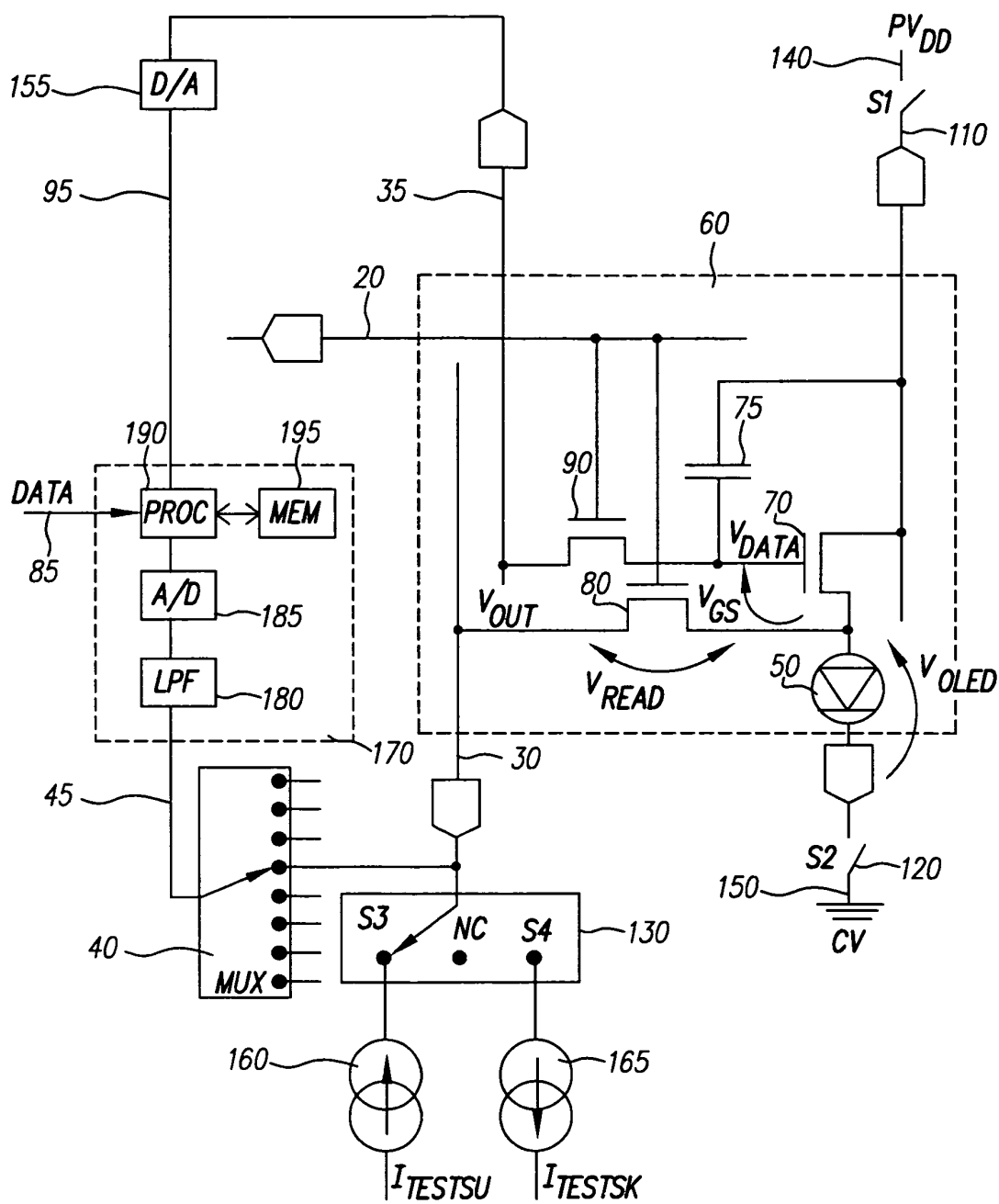


FIG. 2

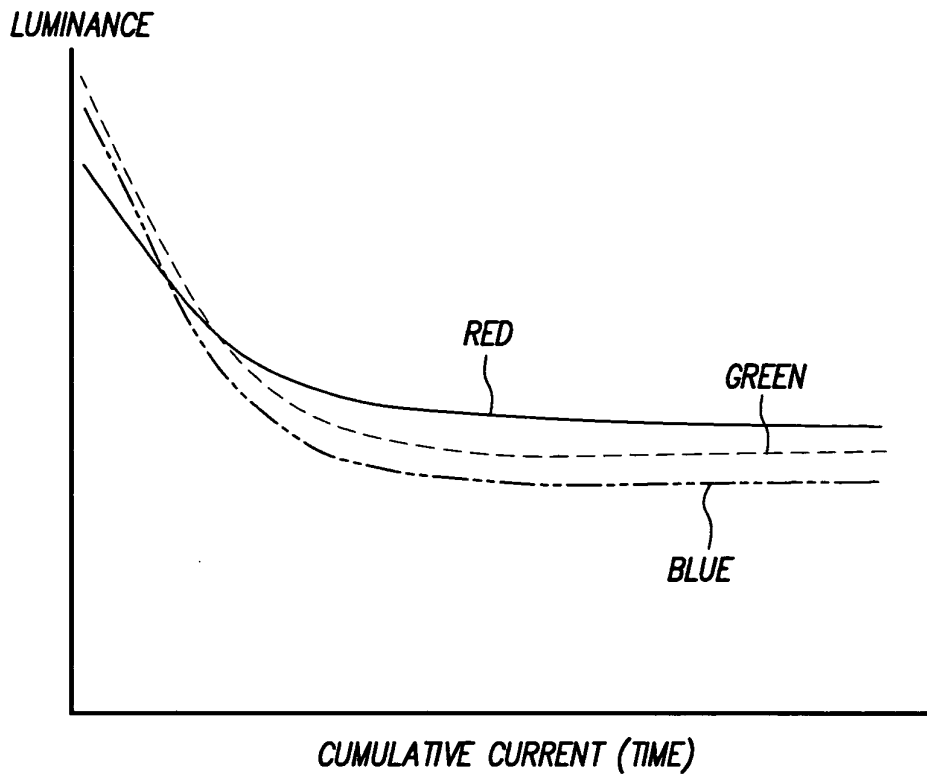


FIG. 3A

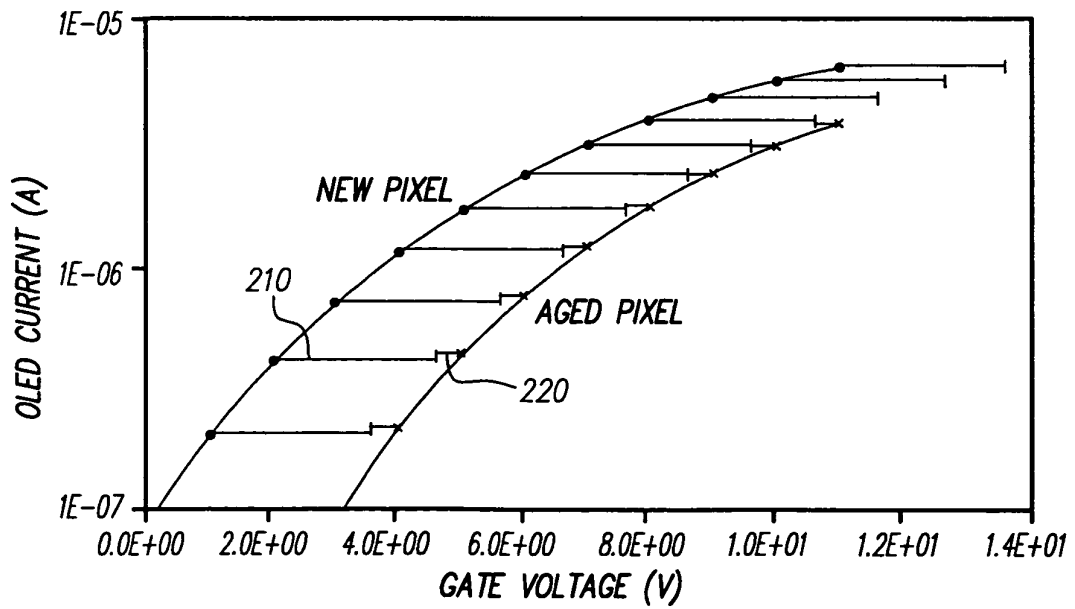


FIG. 3B

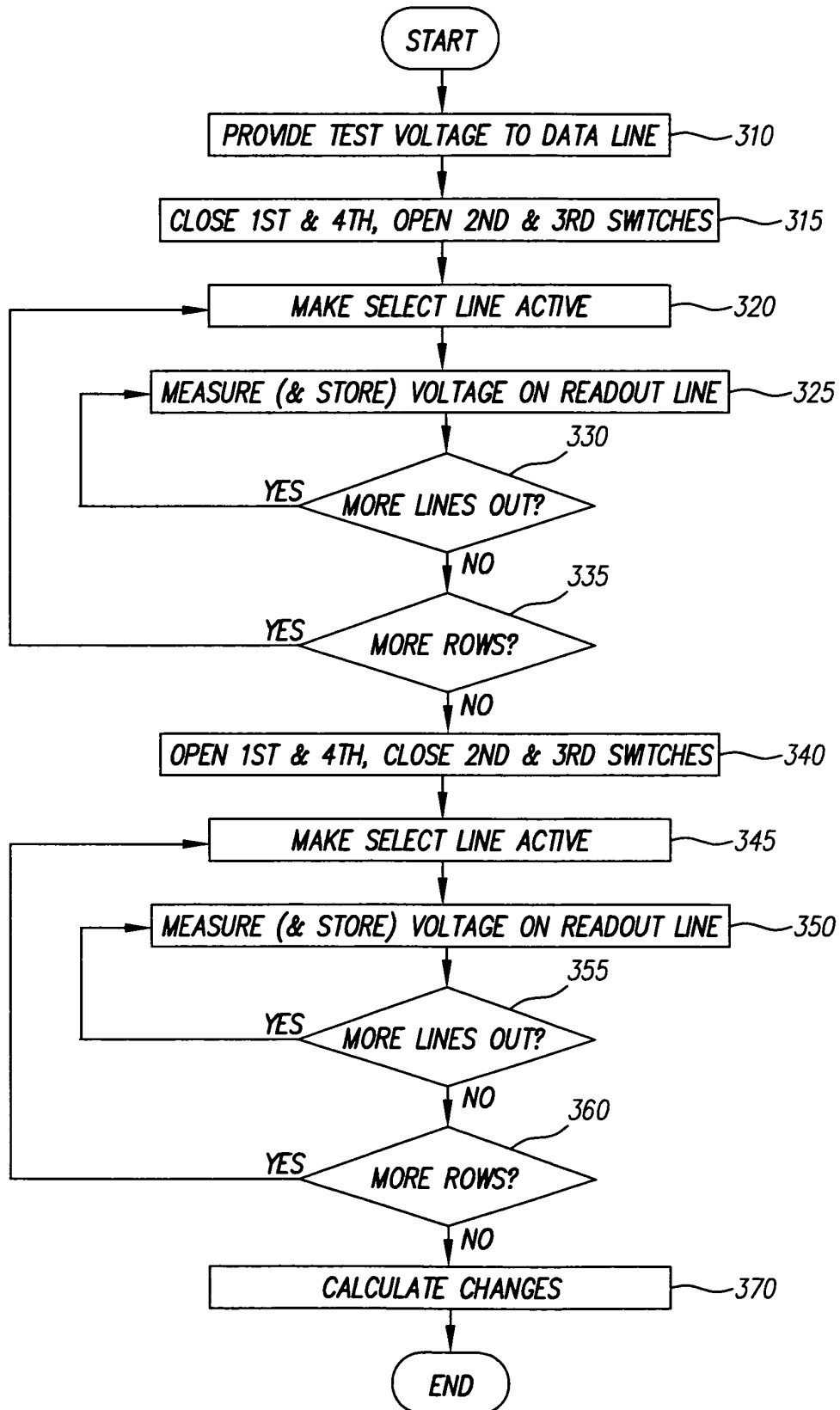


FIG. 4

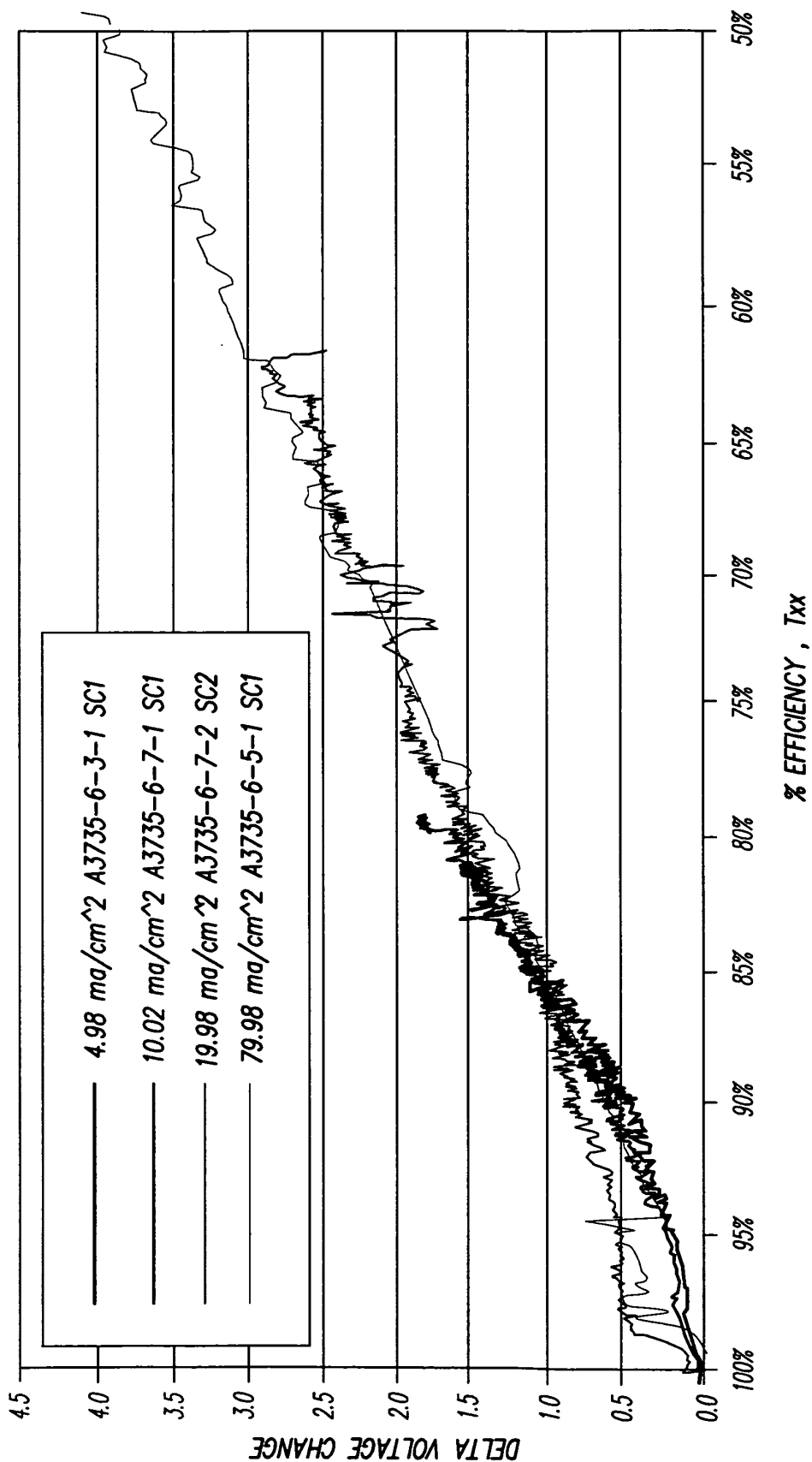


FIG. 5

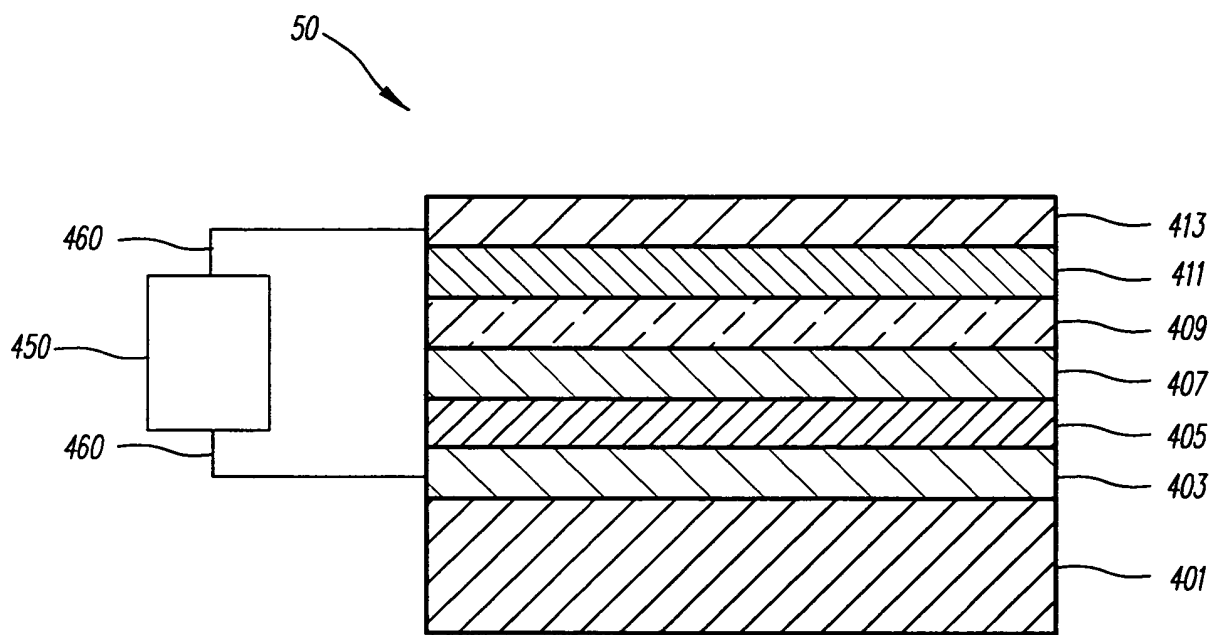


FIG. 6

REFERENCES CITED IN THE DESCRIPTION

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专利名称(译)	补偿OLED显示器中老化的方法		
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外部链接	Espacenet		

摘要(译)

一种补偿OLED驱动电路中的变化的方法包括：提供驱动晶体管;提供第一电压源和第一开关;提供连接到驱动晶体管的OLED器件。测量电压并用于补偿OLED驱动晶体管的变化。

